

INFORMATION DISCLOSURE STATEMENT

Applicant : Sato et al.
App. No : 10/540,056
Filed : June 22, 2005
For : POSITIVE RESIST COMPOSITION
AND METHOD OF FORMING
RESIST PATTERN
Examiner : Chu, John S Y.
Art Unit : 1795

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November 15, 2007

(Date)


Neil S. Bartfeld, Ph.D., Reg. No. 39,901

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Enclosed for filing in the above-identified application is a PTO/SB/08 Equivalent listing 12 references to be considered by the Examiner. Also enclosed are 2 foreign patent references as listed on the Information Disclosure Statement.

This Information Disclosure Statement is being filed before the mailing date of a final action and before the mailing of a Notice of Allowance. This Statement is accompanied by the fees set forth in 37 C.F.R. § 1.17(p). The Commissioner is hereby authorized to charge any additional fees which may be required or to credit any overpayment to Account No. 11-1410.

Respectfully submitted,

KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated: 11/15/07

By: 

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